

**Latest News** 

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**GOVERNMENT & POLICY** 

## **Academy Elects New Members**

## NAS elects 72 new members and 18 foreign associates from 16 countries

## William G. Schulz

The National Academy of Sciences announced the election of 72 new members and 18 foreign members today during its 143rd annual meeting in Washington, D.C. The new members bring the total U.S. membership in NAS to 2,013 and its foreign membership to 371.

Of the new members, the following people are chemists or work in areas related to chemistry and the chemical sciences:

Wolfhard Almers, Oregon Health & Science University, Portland

Richard M. Amasino, University of Wisconsin, Madison

**David Baker,** Howard Hughes Medical Institute and University of Washington, Seattle

Jillian F. Banfield, University of California, Berkeley

Paul F. Barbara, University of Texas, Austin

**Bonnie Bassler,** Howard Hughes Medical Institute and Princeton University

David M. Ceperley, University of Illinois, Urbana-Champaign

Mark E. Davis, California Institute of Technology

William A. Eaton, National Institutes of Health

Barbara J. Finlayson-Pitts, University of California, Irvine

**Joachim Frank,** Howard Hughes Medical Institute and New York State Department of Health

**Stephen P. Goff,** Howard Hughes Medical Institute and Columbia University College of Physicians & Surgeons

Laura H. Greene, University of Illinois, Urbana-Champaign

Eric J. Heller, Harvard University

Brian M. Hoffman, Northwestern University

Charles H. Langmuir, Harvard University

Michael A. Marletta, University of California, Berkeley

Ann E. McDermott, Columbia University

Jose N. Onuchic, University of California, San Diego

Christian R. H. Raetz, Duke University Medical Center

**David W. Russell**, University of Texas Southwestern Medical Center

Mark H. Thiemens, University of California, San Diego

David A. Tirrell, California Institute of Technology

Carl Wu, National Institutes of Health

**FOREIGN ASSOCIATES** 

Chunli Bai, Chinese Academy of Sciences

Harold W. Kroto, Florida State University, Tallahassee

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